

Prof. Mel Ulmer

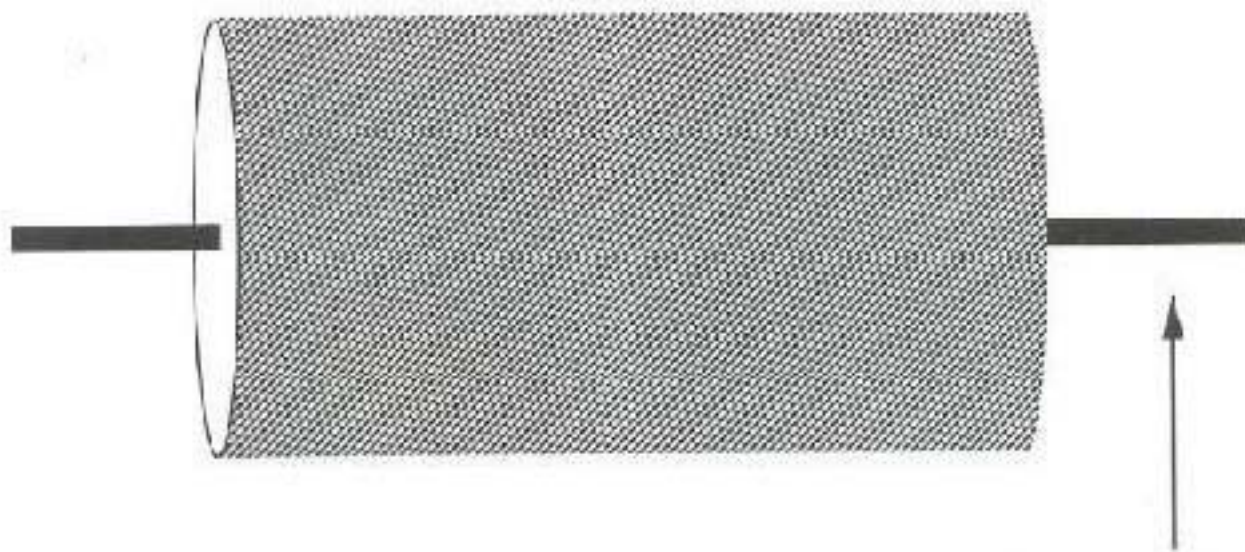
DEPT OF PHYSICS

&

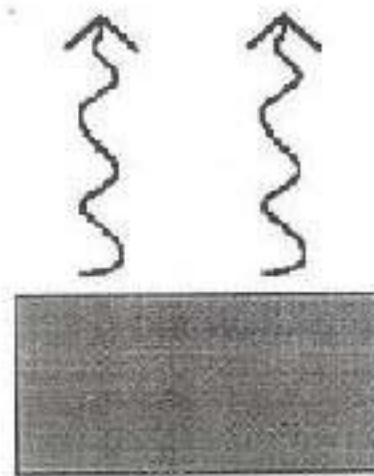
ASTRONOMY

The Concept:

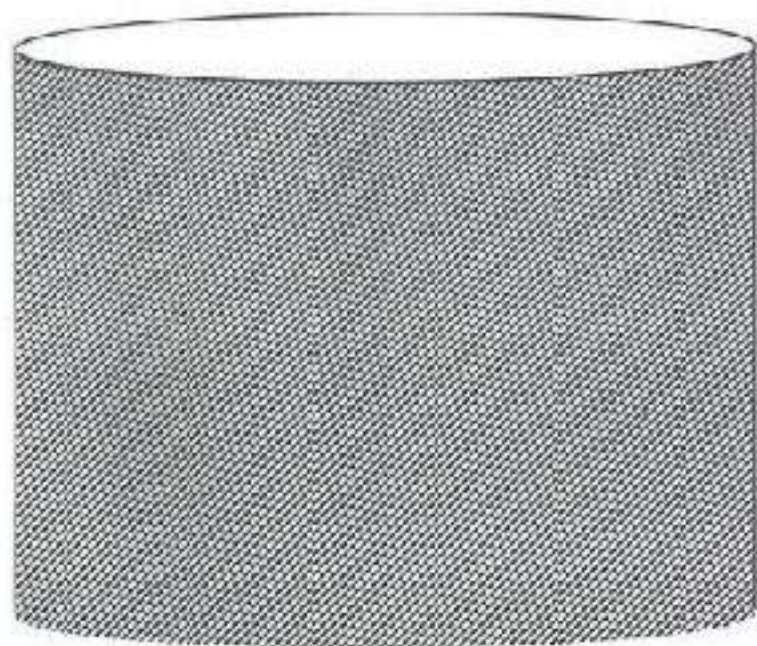
Intact Electroforming Multilayer Process



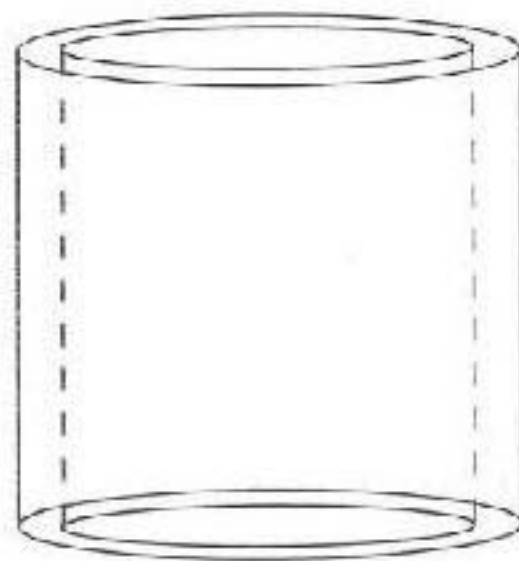
Rotisserie



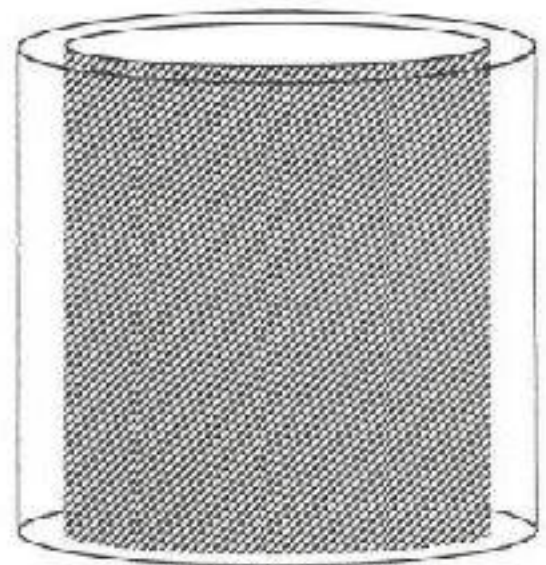
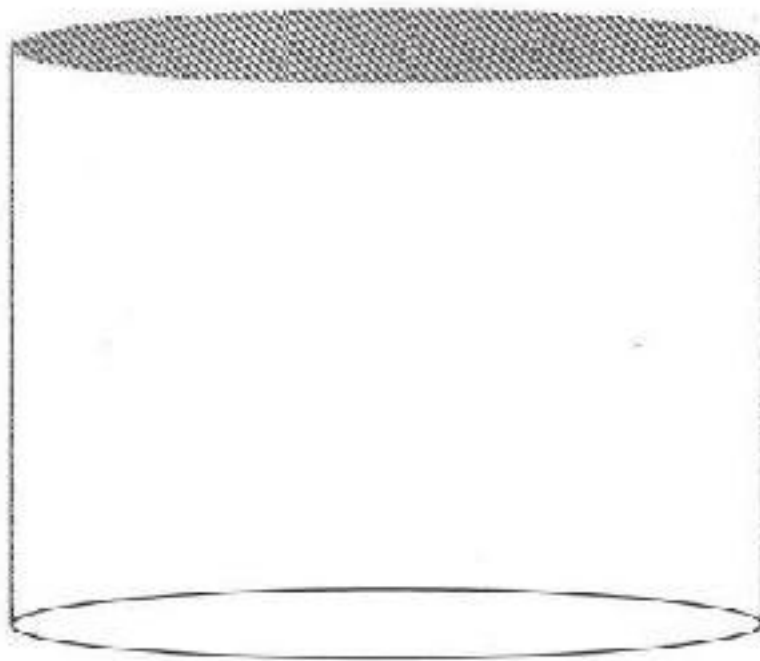
Sputtering Gun



Mandrel & Multilayer

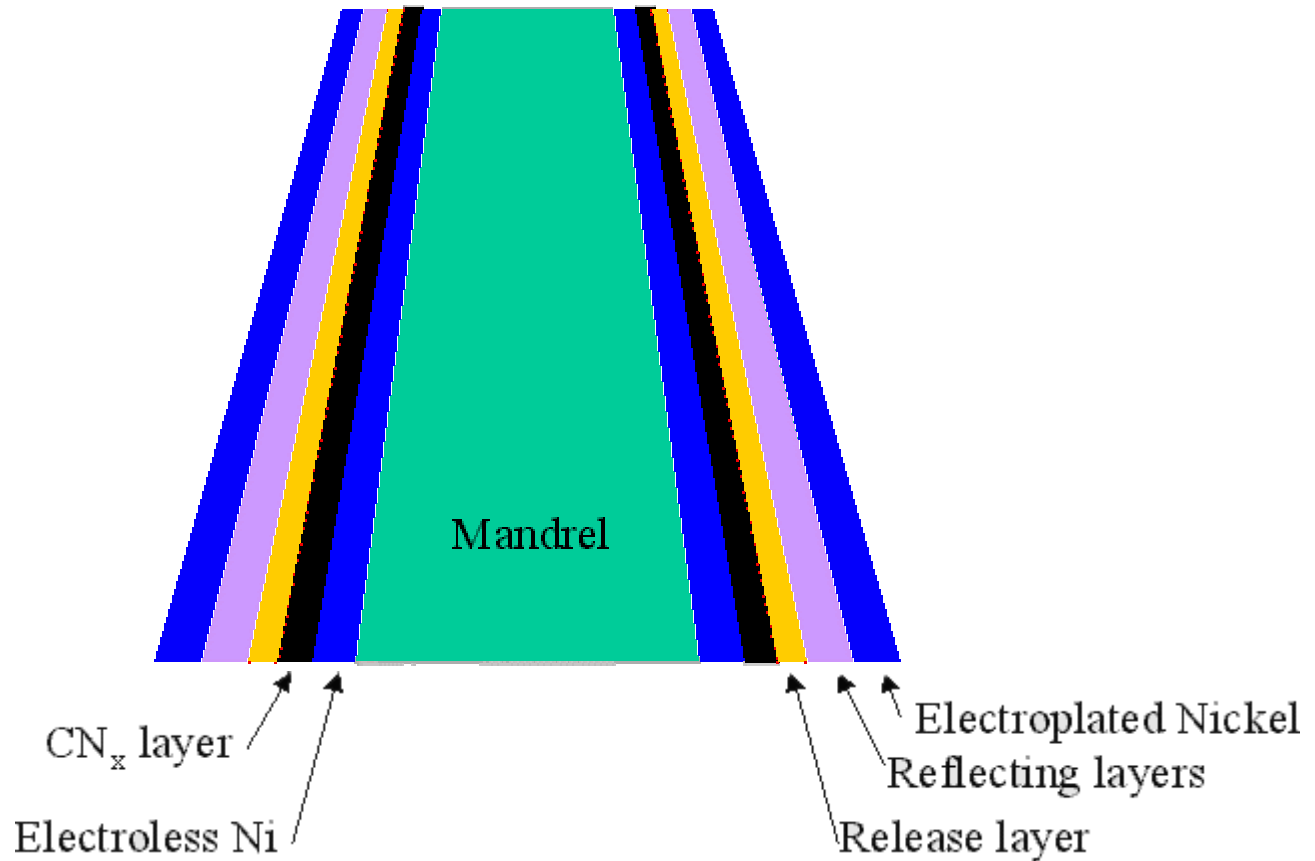


Mandrel with electrodeposited nickel



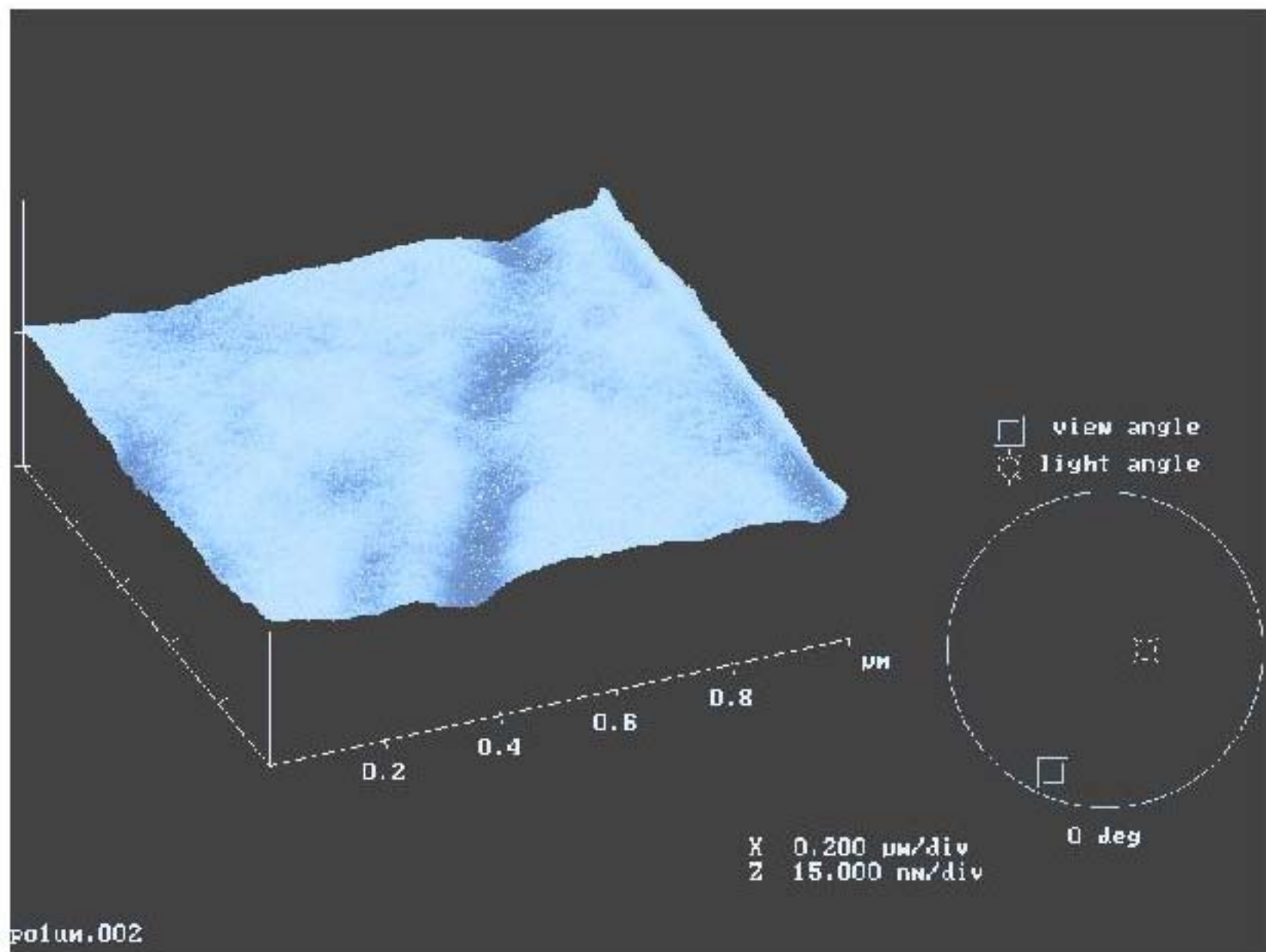
Removed Electroform.
Multilayers on inside.

Coated Mandrel



Advantages of IEMP:

- Coat Mandrel => Focal Length, small as 1-2 meters => SMEX is possible
- Electroforming offers the best angular resolution (< 10 arc sec) outside custom figuring
- An additional advantage of process at NU = CNx coating (10 nm) smooths & protects



Now the entire process:

Coat mandrel with CNx

Coat mandrel with release layer

Coat with multilayers

Coat with adhesion layers

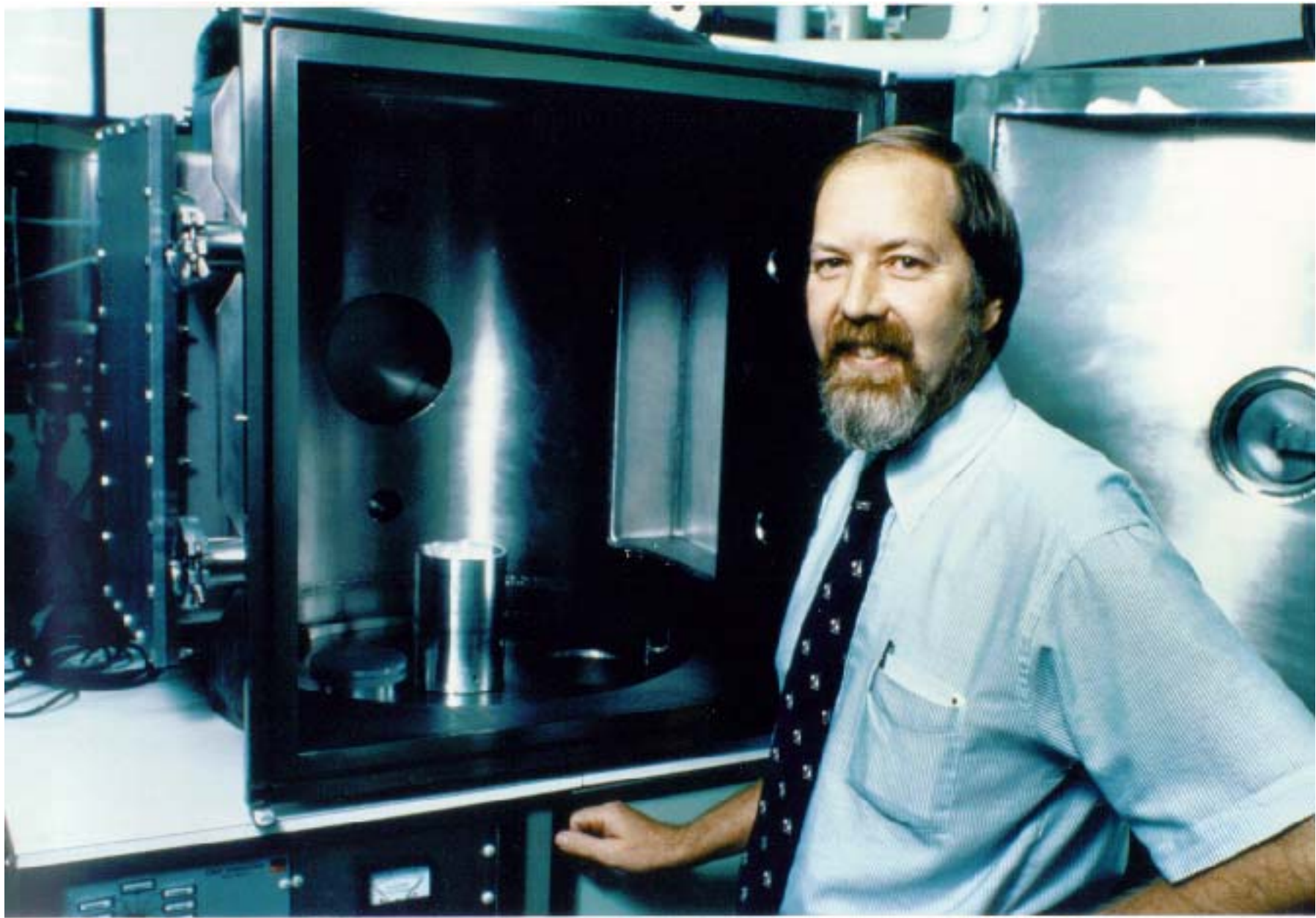
Electroform

Remove electroform

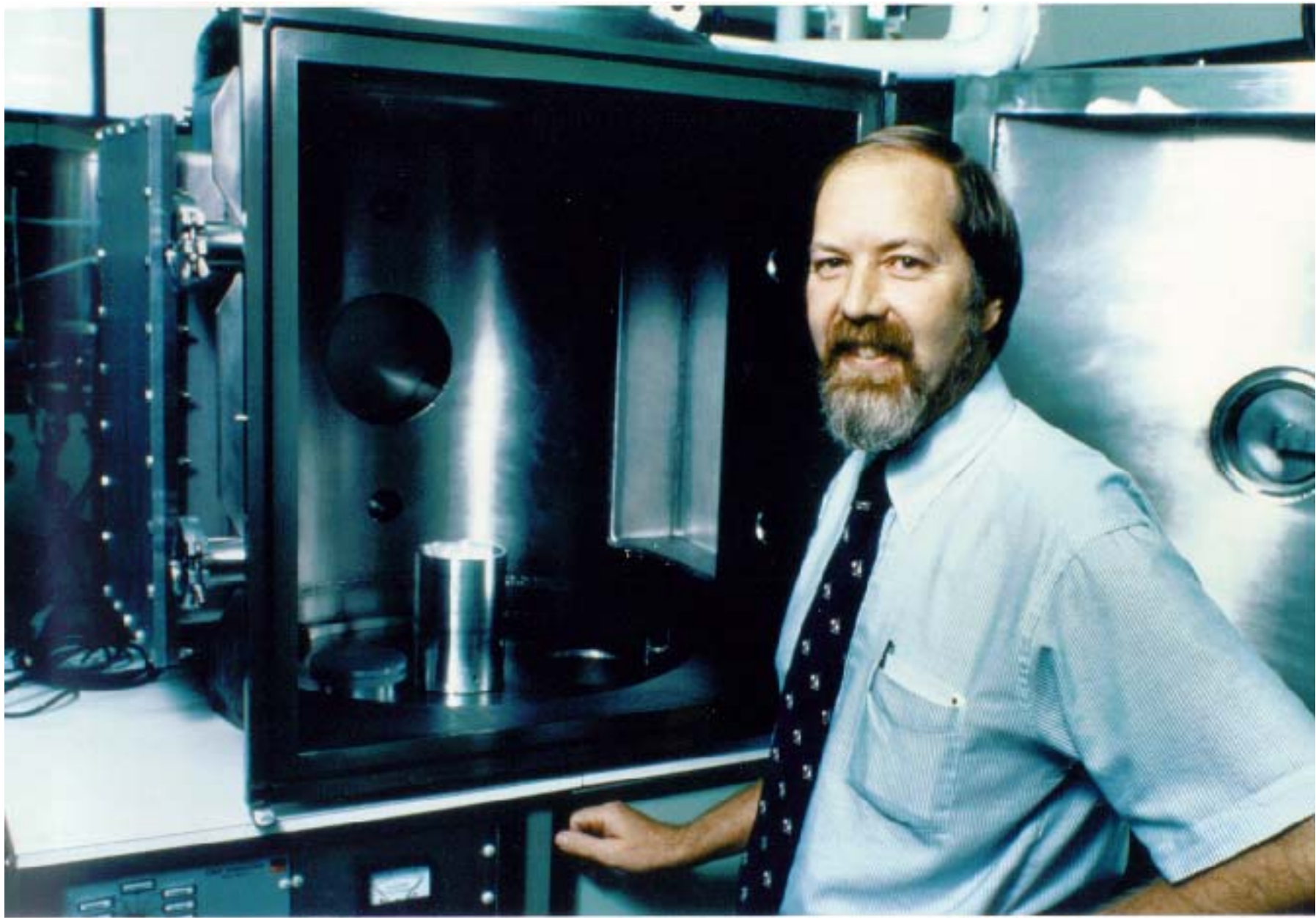
Remove release layer

**Therefore, Total Institutional
Integration is**

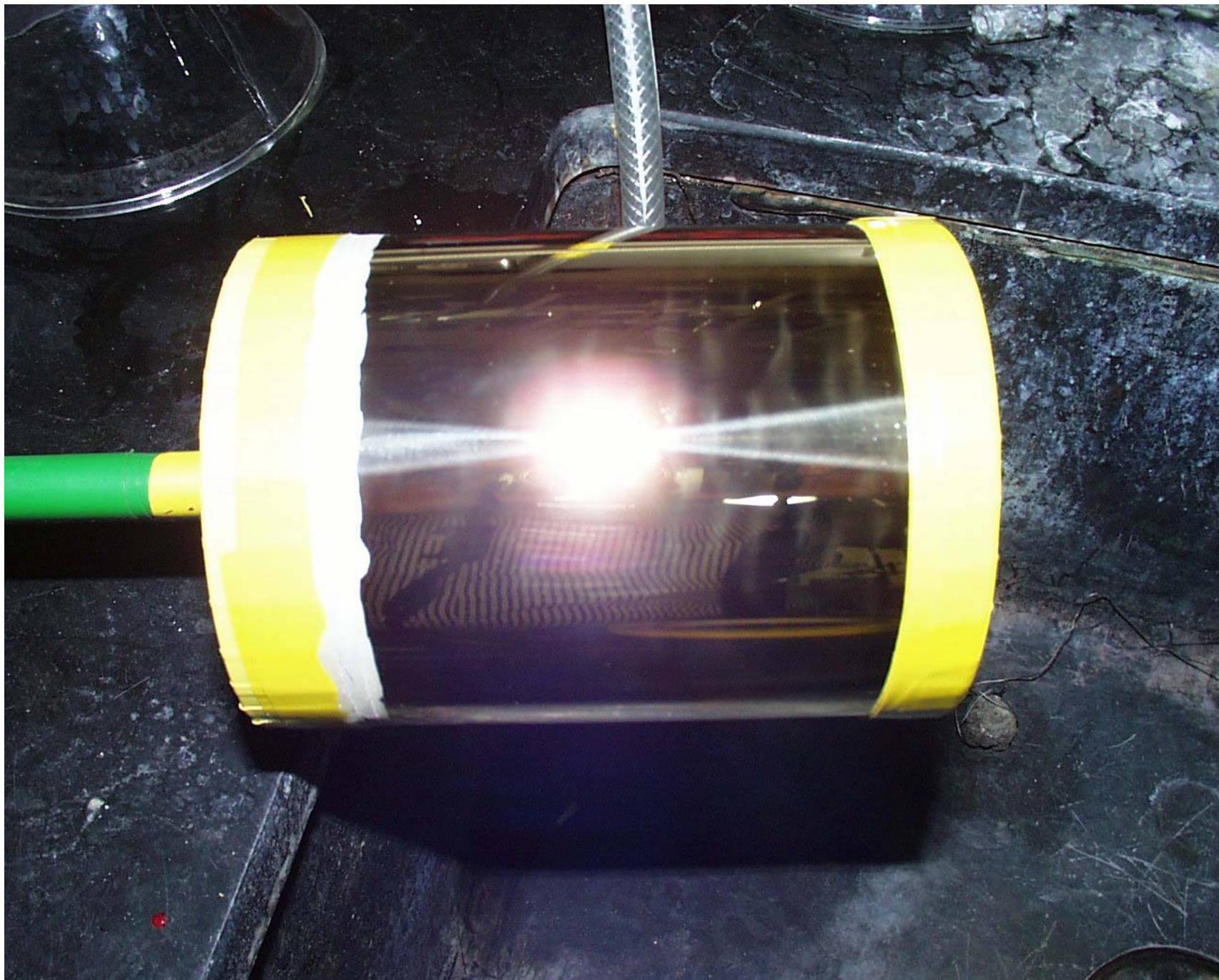
VERY IMPORTANT



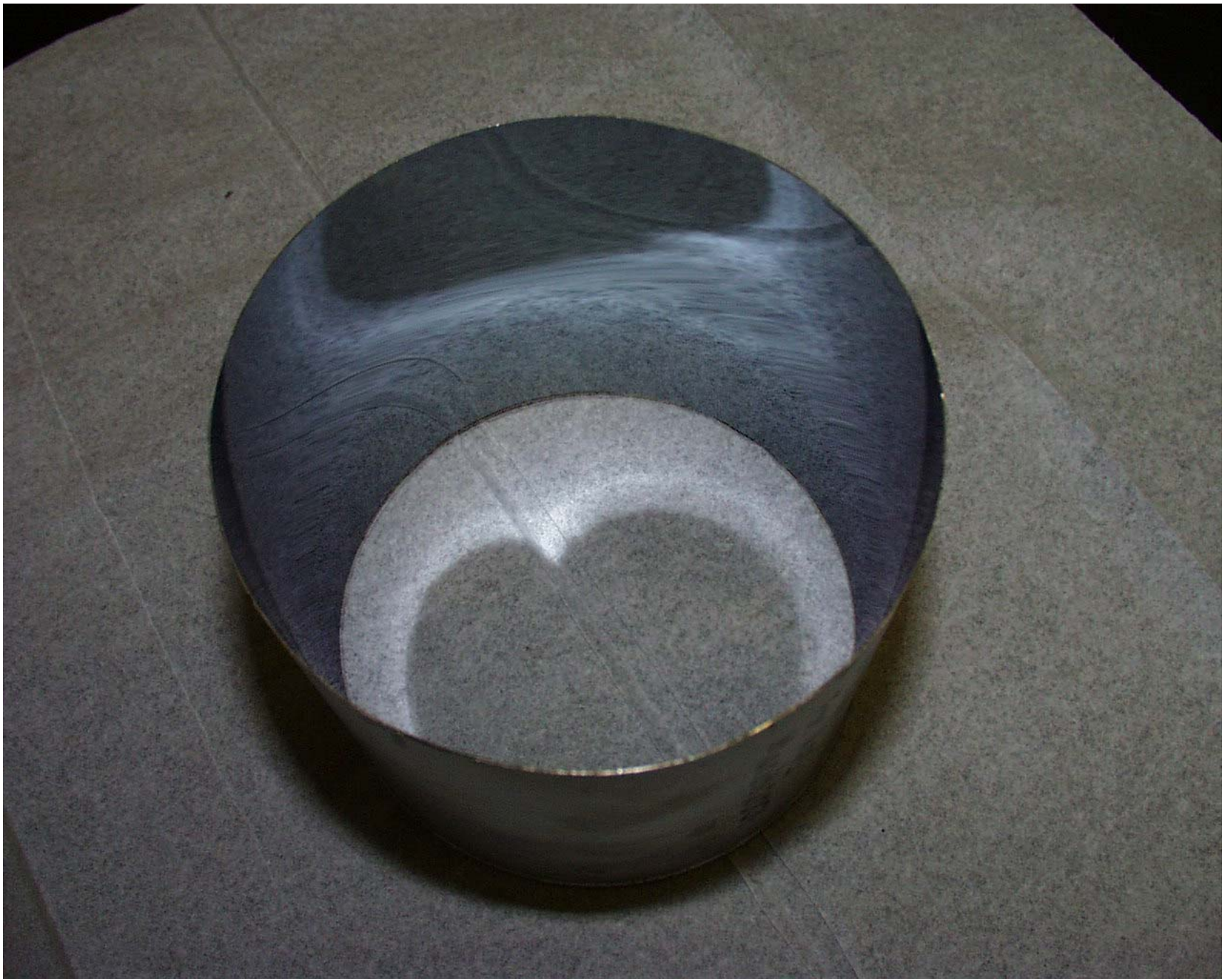




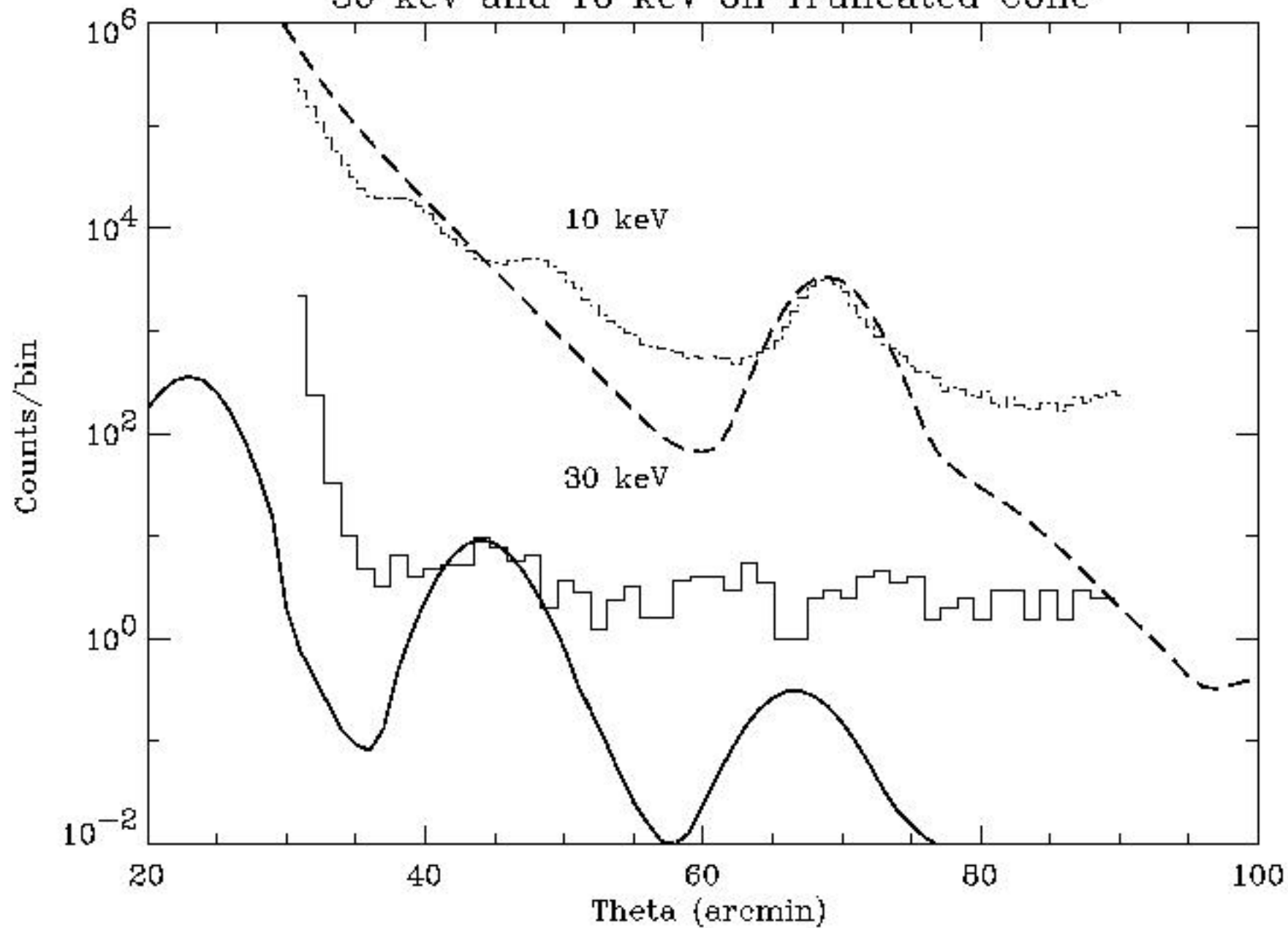


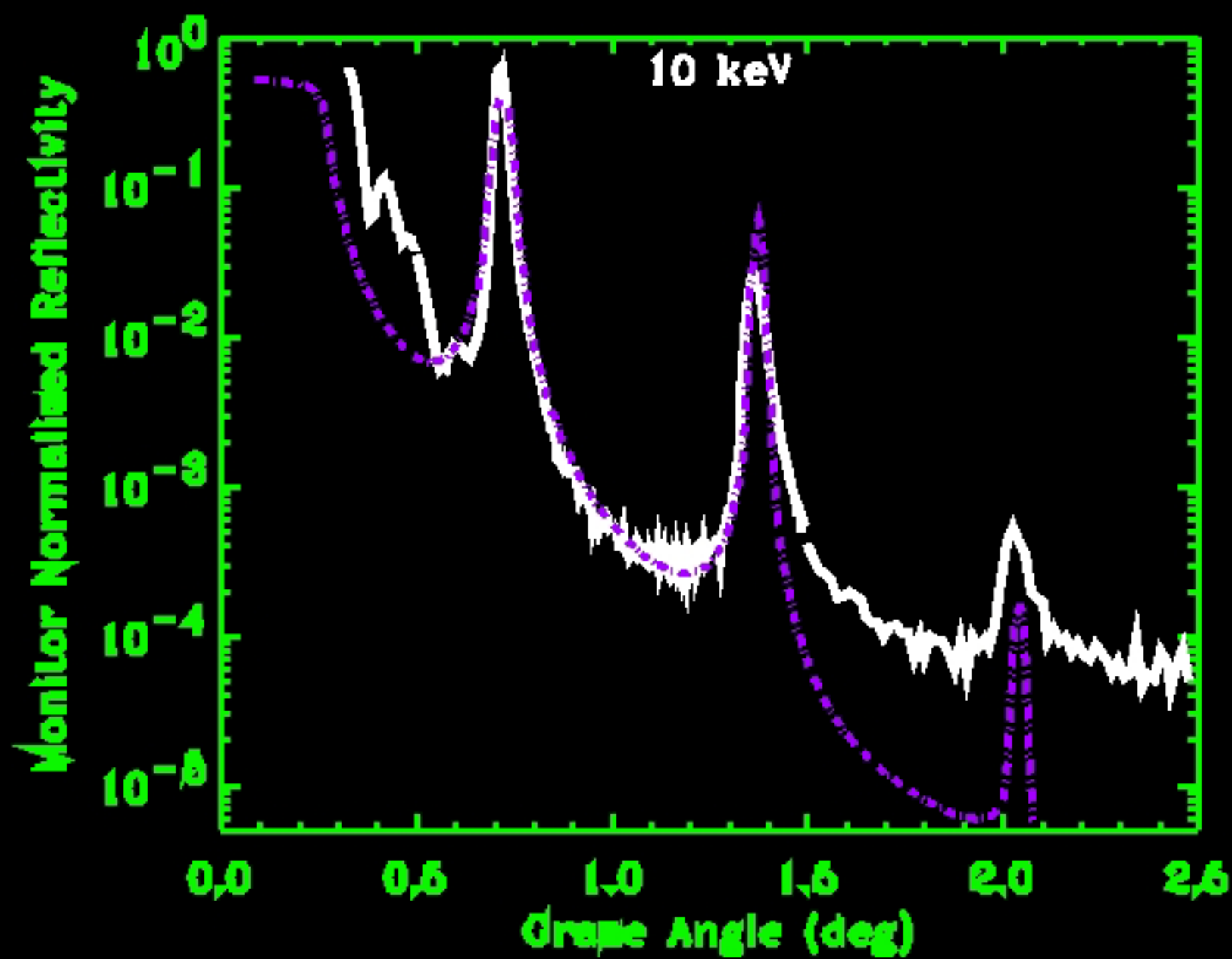




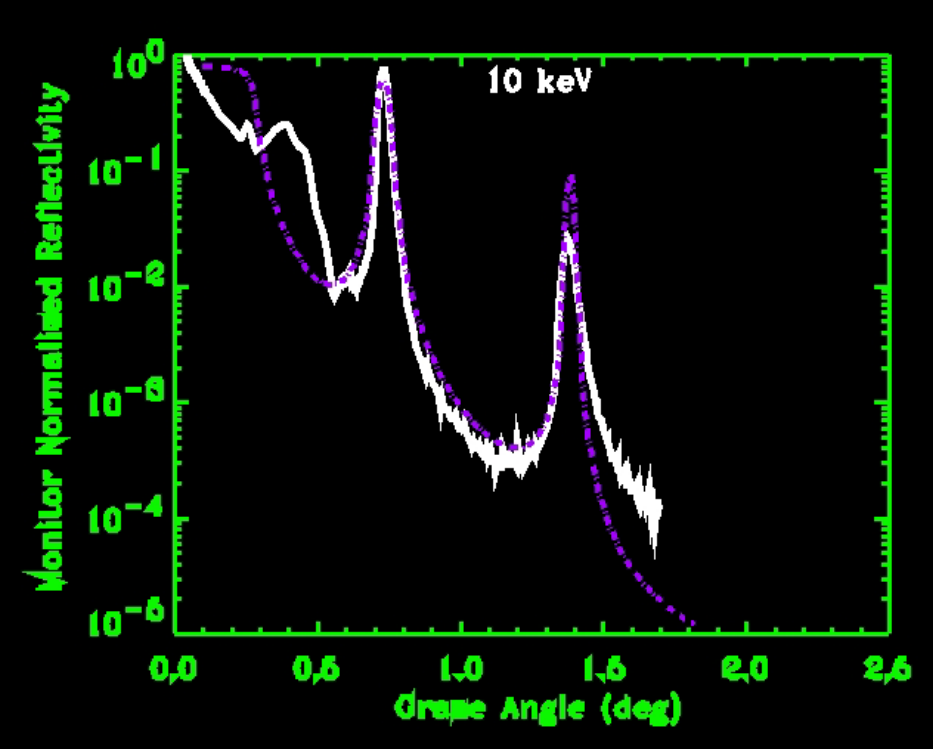


30 keV and 10 keV on Truncated Cone

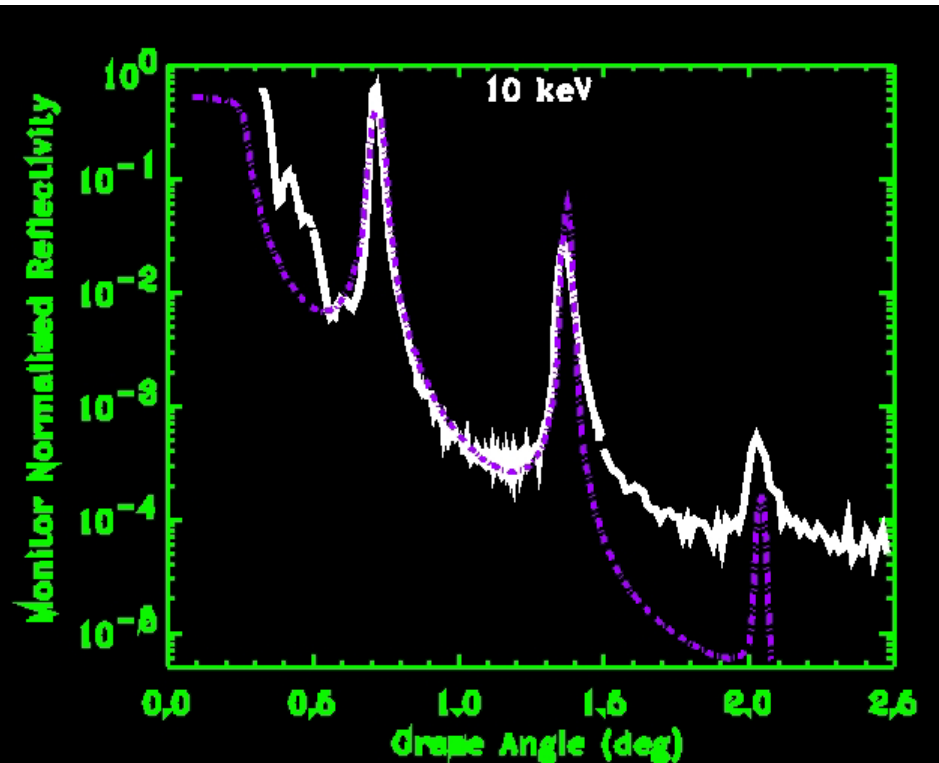




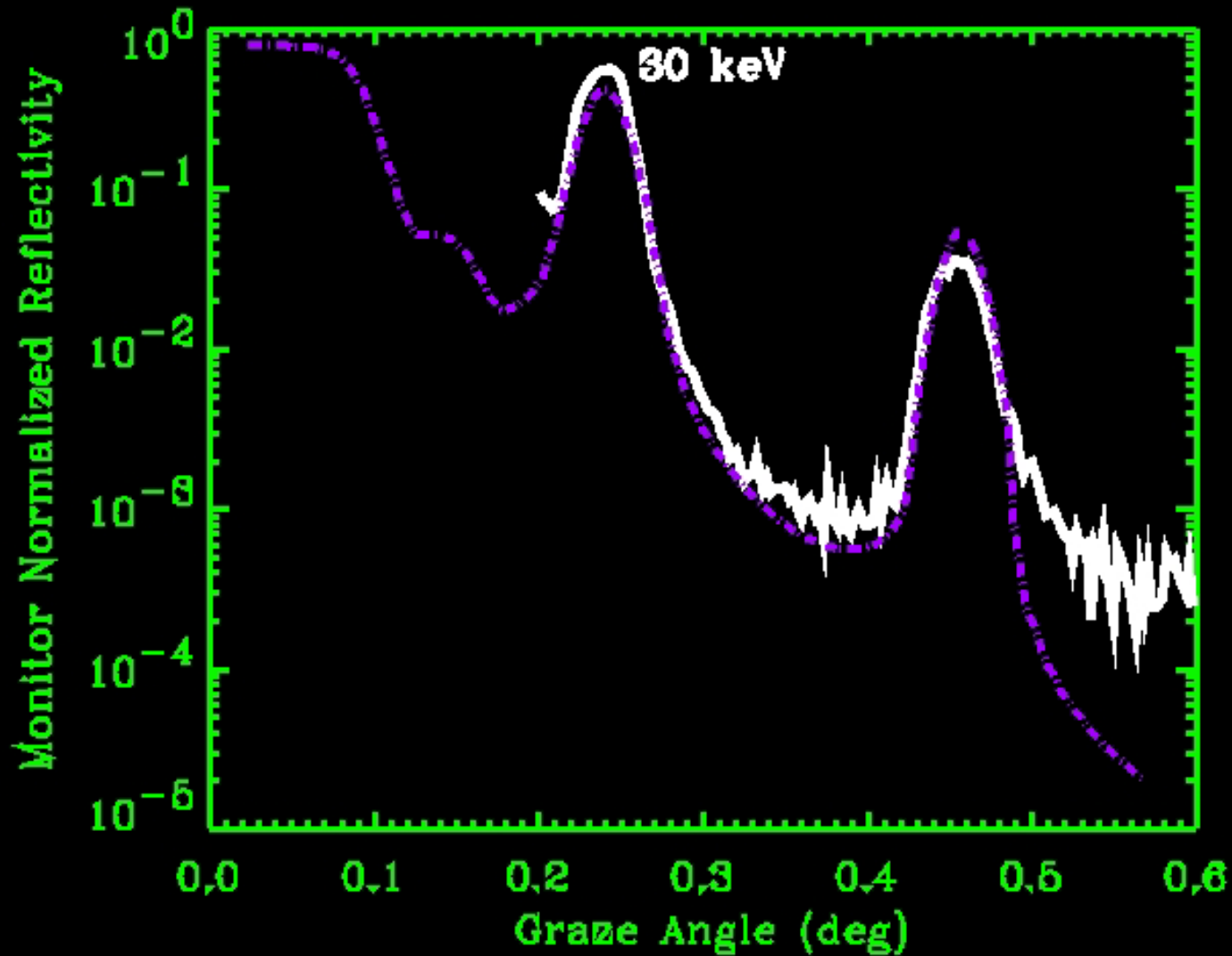
Two different
orientations about
optical axis, same
energy; W/Si 5.29 nm



About 90 deg
rotation



Higher Energy



Follow Up & Evaluation:

Correction for Geometrical Effects at 10 keV:

Evaluated a 1 cm segment, derived 17 % reflectivity

At first Bragg peak

Optical trace of 1 cm segment verified geo. corr.

Si “witness sample” 16% reflectivity

More Optical Evaluation:

Mandrel pre- CNx coating

Roughness 1.1-3.2 nm

Mirror Segment Roughness 0.5-0.6 nm!

Agrees with fit to X-ray data

Conclusion: Excellent Multilayers because:

- Same Bragg angles at different energies, more penetrating versus less
- Narrow Bragg peaks
- One multilayer d-spacing = 5.29 nm fits all
- Same Bragg angles at different axis rotations
- All the data point towards 14-20% reflectivity

Overall conclusions

- We can put viable multilayers on the inside of mirrors!
- The entire process:
 - CNx plus IEMP are a success
 - For high quality optics
 - flexibility in design, IEMP is it.
- The only problem may be mass

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Con X

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Where would we like to go from here?

Progress to new chamber with graded d-spacing

Coat our much better Zeiss Mandrel

Then replicate success on a Wolter I

Test MSFC

Then?? A SMEX path finder? A Midex Survey
or ??

The

End